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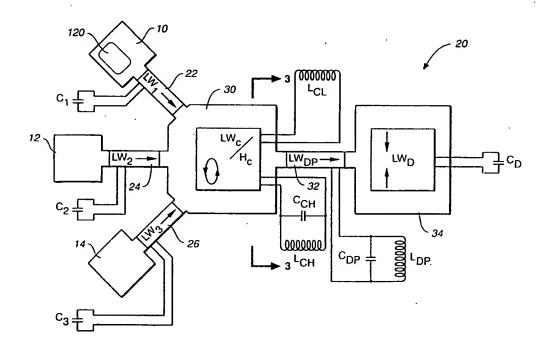
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(54) Title: MICROFABRICATED REACTOR



(57) Abstract

An integrated microfabricated instrument (20) for manipulation, reaction and detection of microliter to picoliter samples. The instrument (20) is suited for biochemical reactions, particularly DNA-based reactions such as the polymerase chain reaction, that require thermal cyclind since the inherently small size of the instrument facilitates rapid cycle times. The integrated nature of the instrument (20) provides accurate, contamination-free processing. The instrument (20) may include reagent reservoirs (10, 12, 14), agitators and mixers (LWc), heaters (Hc), and optical or electromechanical sensors (LWd). Ultrasonic Lamb-wave devices may be used as sensors (LWd), pumps (LW1, LW2, LW3), and agitatos (LWc).

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MICROFABRICATED REACTOR

RELATED APPLICATIONS

This application is related to U.S. Patent 5,129,261, Serial No. 07/467,412, filed January 18, 1990 and application Serial No. 07/162,193, filed February 29, 1988, now abandoned, for a Plate-mode Ultrasonic Sensor. The entire disclosures of these applications are hereby incorporated by reference.

BACKGROUND OF THE INVENTION

- The present invention relates generally to instruments for chemical reaction control, product and reactant manipulations, detection of participating reactants and resultant products, and more particularly to integrated microfabricated instruments which perform microscale chemical
- reactions involving precise control of parameters of the reactions. The parameters of the reaction controlled by the instrument may be temperature, pressure, concentration of reactants, the intensity or frequency of incident light, electromagnetic
- 20 fields, or ultrasonic pressure waves, etc.

The term "integrated microfabrication" is used herein to refer to all processes used for batch production of semiconductor microelectronics, and all related microfabrication processes such as LIGA (see R. S. Muller, R. T. Howe, S. D. Senturia, R. L. Smith, and R. M. White, ed. MICROSENSORS, IEEE Press, 472 pages, 1990). Microfabrication technologies include, but are not limited to, sputtering. electrodeposition, low-pressure vapor deposition, 10 photolithography and etching. Microfabricated devices are usually formed on crystalline semiconductor substrates such as silicon or gallium arsenide. Noncrystalline materials such as glass or certain polymers may be used although crystalline 15 materials provide certain advantages. The shapes of crystalline devices can be precisely controlled since etched surfaces are generally crystal planes, and crystalline materials may be bonded by processes such as fusion at elevated temperatures or the field-20 assisted method (Mallory bonding). Materials which are not semiconductors, such as quartz or glass, may be used, though semiconductor materials provide the advantage that electronic circuitry may be integrated into the system by the use of conventional integrated-circuit fabrication techniques. 25

Monolithic microfabrication technology now allows the production of electrical, mechanical, electromechanical, optical, chemical and thermal devices including pumps, valves, heaters, mixers and species detectors for microliter to nanoliter quantities of solids, liquids and gases. Microscale sensors include optical waveguide probes and ultrasonic flexural-wave sensors. The integration of these devices into a single system allows for the batch production of microscale reactor-based analytical instruments. Integrated microinstruments

may be applied to biochemical, inorganic, or organic chemical reactions to perform biomedical and environmental diagnostics, and biotechnological processing and detection.

- 5 Such integrated microfabricated devices can be manufactured in batch quantities with high precision, yet low cost, thereby making recyclable and/or disposable single-use devices practical. Alternatively, the instrument may consist of an array 10 of reaction instruments which are to operate in parallel to simultaneously perform a number of related reactions. Operation of such instruments is easily automated, further reducing costs. analysis can be performed in situ, the likelihood of 15 contamination is very low. Because of the inherently small sizes of such devices, the heating and cooling can be extremely rapid, and the devices can have very low power requirements. Such devices may be powered by batteries or by electromagnetic, capacitive, 20 inductive or optical coupling.
- Small volumes and high surface-area to volume ratios provide microfabricated reaction instruments with a high level of control of the parameters of a reaction. Heaters may produce temperature cycling or ramping, sonochemical and sonophysical changes in conformational structures may be produced by ultrasound transducers, and polymerizations may be generated by incident optical radiation.
- Synthesis reactions, and especially synthesis chain reactions such as the polymerase chain reaction (PCR), are particularly well-suited for microfabricated reaction instruments. PCR can selectively amplify a single molecule of DNA (or RNA)

of an organism by a factor of 10⁶ to 10⁹. This wellestablished procedure requires the repetition of
heating (denaturing) and cooling (annealing) cycles
in the presence of an original DNA target molecule,
specific DNA primers, deoxynucleotide triphosphates,
and DNA polymerase enzymes and cofactors. Each cycle
produces a doubling of the target DNA sequence,
leading to an exponential accumulation of the target
sequence. PCR-based technology has been applied to a
variety of analyses, including environmental and
industrial contaminant identification, medical and
forensic diagnostics, and biological research.

The procedure involves: (1) processing of the sample to release target DNA molecules into a 15 crude extract; (2) addition of an aqueous solution containing enzymes, buffers, deoxyribonucleotide triphosphates (dNTPS), and oligonucleotide primers; (3) thermal cycling of the reaction mixture between two or three temperatures (e.g., 90-96, 72, and 37-20 55°C); and (4) detection of amplified DNA. Intermediate steps which incorporate signal-producing and/or surface-binding primers, or which purify the reaction products, via, for example, electrophoresis or chromatography may be introduced. A problem with 25 standard PCR laboratory techniques is that the PCR reactions may be contaminated or inhibited by introduction of a single contaminant molecule of extraneous DNA, such as those from previous experiments, or other contaminants, during transfers 30 of reagents from one vessel to another.

PCR reaction volumes are presently typically on the order of 50 microliters. A thermal cycle typically consists of heating a sample to a first temperature, maintaining the sample at the first temperature, cooling the sample to a second

lower temperature, and maintaining the temperature at that lower temperature. The rate at which the sample is heated is generally limited by the heater rather than the rate of heat transfer to the sample. Presently, each of the four stages of a thermal cycle requires approximately one minute, and the time required for twenty to forty complete thermal cycles is therefore from about one to three hours. cycling time has been reduced by performing the PCR 10 reaction in capillary tubes (see C. T. Wittwer, G. C. Fillmore, and D. J. Garling, Analytical Biochemistry, 186, pp. 328-331 (1990)). A high-power forced air heater was used to heat the tubes. The thinnest capillary tubes contained a sample volume of about 15 ten microliters. Each cycle consisted of a heating step, a waiting period, a cooling step and another waiting period, and each step required approximately

Although the PCR reaction requires thermal cycling of the reagents, any reaction that benefits from precise temperature control, and/or rapid thermal cycling, thermal ramping, or any other temperature variation of reagents with time (hereinafter to be referred to as temperature programming) will be well suited for the microfabricated reaction instrument of the present invention.

fifteen seconds.

An object of the present invention is therefore to provide a integrated microfabricated 30 reactor.

Another object of the present invention is to provide a reactor-based instrument for inorganic, organic and biochemical reactions, and in particular for diagnostics. 71 1 24/ 02414

Another object of the present invention is to provide a reactor which provides high-precision control of reaction parameters.

Another object of the present invention is to provide a reactor which provides high-precision temperature control.

Another object of the present invention is to provide a reactor which provides rapid highprecision thermal cycling, ramping or programming.

- Another object of the present invention is to provide a closed system reactor which is self-contained, e.g. which is shipped from the factory containing the reagents, thereby minimizing the susceptibility to contamination.
- Another object of the present invention is to provide low-cost reaction and/or detection systems.

Another object of the present invention is to provide an instrument for in situ reactions which 20 may be powered by incident electromagnetic radiation or batteries.

Another object of the present invention is to provide arrays of microfabricated reaction chambers which may operate in parallel or series.

25 Additional objects and advantages of the invention will be set forth in the description which follows, and in part will be obvious from the description, or may be learned by practice of the invention. The objects and advantages of the 30 invention may be realized and obtained by means of

the instrumentalities and combinations particularly pointed out in the claims.

SUMMARY OF THE INVENTION

The present invention is directed to an instrument for in situ chemical reactions in a microfabricated environment. The instrument is especially advantageous for biochemical reactions which require high-precision thermal cycling, particularly DNA-based manipulations such as PCR, since the small dimensions typical of microinstrumentation promote rapid cycling times.

The present invention provides a reaction instrument comprised of integrated microfabricated elements including a reagent chamber and a means for manipulating the reaction of the reagents.

BRIEF DESCRIPTION OF THE DRAWINGS

The accompanying drawings, which are incorporated in and constitute a part of the specification, schematically illustrate a preferred embodiment of the invention and, together with the general description of the preferred embodiment given below, serve to explain the principles of the invention.

Figure 1 shows a cut-away perspective view of a reaction instrument of the present invention mounted in a power source/control apparatus.

Figure 2 is a schematic of a reaction instrument of the present invention.

Figure 3 shows a cross-sectional view of a 30 reaction chamber of the present invention.

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Figures 4(a) through 4(f) show crosssectional views of the stages of fabrication of a reaction chamber of the present invention.

Figure 5 shows a top view of a reaction 5 chamber (dashed outline) below the piezoelectric and ground plane layers.

Figure 6a shows the typical flow velocity profile field for a fluid forced through a conduit with static bottom and side surfaces, and Figure 6b 10 shows the flow velocity profile for a fluid pumped through a conduit by a flexural-wave pump.

Figure 7 shows gel electrophoretic results verifying the amplification of an HIV genetic sequence in a microfabricated reaction chamber of the 15 present invention.

DESCRIPTION OF THE PREFERRED EMBODIMENT

The microinstrument of the present invention has integrated microfabricated components that perform reactant and product manipulations and detection on microliter to picoliter samples. By the selection and integration of appropriate microfabricated devices, a precise and reliable reaction and analysis instrument for PCR-based diagnostics is implemented.

The instrument may be fabricated in a wide variety of different forms. Many microinstruments may be manufactured on a single wafer and can run in parallel, allowing the processing and analysis of several target agents and controls simultaneously. 30 Individual small and disposable dies, each a complete microinstrument, may be fabricated. The device may be fabricated to allow a continual flow of reagents through the instrument. A reagent reservoir of the

microinstrument may have a thin silicone rubber wall so that the reagent may be inserted into the microinstrument by a hypodermic needle.

Alternatively, a needle may be integrated into the microinstrument so that a patient can be pricked by the needle and a blood sample, or any other type of body fluid, will directly enter the instrument. An integrated needle can also be used to extract body fluids from plants and animals. The reagent may also be loaded into the microinstrument by pipetting, a modified ink-jet printing process, or other means at the factory. The reagent may be lyophilized or dried, or previously stored in the chamber.

Detection signals may be processed and

stored by integrated microelectronic devices so that result interpretation and control mechanisms (which may utilize feedback) can be integrally contained on the microinstrument. The low power needs of microinstrumentation allows such systems to be

powered by incident electromagnetic radiation, low voltage batteries, or incident optical radiation converted to electrical energy by on-board photocells.

include reservoirs for retaining reagents, agitators and mixers, heaters to perform denaturing and annealing cycles, pumps, optical and/or electromechanical sensors to discriminate reagents, and reagent separators. Microheaters may be resistive heaters consisting of materials such as polysilicon patterned onto and made an integral part of the microstructure. The micropumps may be Lambwave devices (see U.S. Patent No. 5,006,749, R.M. White, 1991), electrokinetic pumps, or other microfabricated pump structures. The microdetection

instruments may be fluorescence-based optical fiber spectroscopes which utilize microfabricated light sources and detectors (e.g., LEDs or diode lasers and detectors); Lamb-wave sensors (see U.S. patent 5 5,129,261, Serial No. 07/467,412 filed January 18, 1990, and application Serial No. 07/775,631 filed October 10, 1991); electrochemical detection of biochemical molecules by surface plasmon resonance or other processes involving immobilized biochemicals; 10 electrochemical sensing devices; or other appropriate detection methodologies. Surface treatments may be applied to components of the device for reaction enhancement, product separation, and species detection. The surface treatments can be based on 15 numerous well-known procedures such as silanol-based derivatizations or other appropriate treatments. Chemical species separators can utilize microelectrophoresis either in a capillary or within a gel, or can be based on other appropriate 20 methodologies.

One embodiment of the present invention performs the polymerase chain reaction (PCR). minute reagent volumes and the specific reaction sequence of the PCR technique play favorably into the 25 advantages of the present invention. The integrated microsystem provides a highly automated, miniaturized, analytical instrument for very rapid in situ analyses and production of a variety of samples. Integrated microfabricated PCR instruments are 30 capable of performing, in situ, many reactions and manipulations with precise control of temperature, evaporation, small-volume reagent delivery, product separation, isolation and detection. Such highly automated technologies should greatly expedite the 35 use of DNA-based technologies for biomedical (e.g., the Human Genome Project); environmental (e.g.,

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contaminant identification); industrial (e.g., biotechnology); and forensic applications. The principles applied and problems solved in developing a PCR instrument may of course be applied to other chemical reactions, analyses, and syntheses, especially other biochemical reactions, analyses, and syntheses.

PCR in a microdevice can be just one step in a series of manipulations leading to the

10 diagnostic detection of a variety of target species or the use of PCR products in genetic engineering. Physical and chemical treatments such as those described below can also be incorporated into the pre-PCR and post-PCR phases of microdevice-based

15 treatments to augment the reactions in situ. Amplification via PCR yields products that may be subject to further enhancement or utilized for detection of other chemicals. Physical and chemical control via microdevices of biological cells and

20 reagents prior to and after the production of PCR products will expand the number of the potential applications of DNA-based processes and analyses.

Pre-PCR manipulation of target cells or microorganisms can be accomplished with microdevices of the present invention. For example ultrasonic waves may be applied to disrupt and expose cell components through lysis, and to unravel large or long chain molecules such as DNA and proteins via disruption of secondary structure. Cell lysis may also be induced electrically or chemically. Ultrasonic waves and surface chemistry treatments can be used to manipulate cells and cell-contents, as can chemical treatment by stirring and/or mixing reagents from other chambers on the microinstrument.

35 Sonication on a macro-scale in conjunction with

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agitating microparticles, for example, has been used to facilitate the extraction of DNA from parafinembedded fixed cells (M. J. Heller, L. J. Burgart, C. J. Ten Eyck, M. E. Anderson, T. C. Greiner, and R. A. Robinson, Biotechniques, 11, #3, 1991, pp. 372-377). Strategies similar to this which rely on the inherent properties of a microdevice can be used to process intact cells, microorganisms, tissues, and other analytical samples for PCR and subsequent techniques.

Potential post-PCR treatments by the 10 microdevice are also numerous. It should be noted that PCR is often an integral part of the potential application of a device to further biotechnological manipulations and analyses. Once PCR has been 15 performed, post-PCR manipulations can lead to a myriad of possible microdevice-based DNA analyses and treatments. A few examples of such analyses are: large-scale and small-scale DNA sequencing of target species, cell-typing, analysis of PCR products with DNA probes, DNA recombination, DNA fingerprinting, 20 DNA cloning, cell cloning, physical mapping of genes, incorporation of genetic vectors, genetic therapy, treatment and testing of biotechnological processes, and the maintenance of DNA libraries. Such analyses 25 can lead to the use of DNA as vectors to produce cells or other biological entities to make desired products such as proteins or other compounds, or it can be used to produce DNA for use in therapies or biotechnological processes.

order to be incorporated into genetic engineering vectors such as plasmids. The vectors may subsequently be incorporated into target cells for the production of desired compounds. The target cells or moieties and reagents can be stored in

reservoirs on the device and released for exposure to the vectors when the proper physical/chemical conditions have been established. One other potential application would be the in situ (in vitro or in vivo) release of PCR products for direct genetic therapy or manipulations. Direct DNA sequencing of PCR products (single or doublestranded) can be accomplished with the use of unique temperature, enzymatic, or other separation schemes and detection methodologies; all of which can be incorporated into a microdevice.

Detection windows, reflective and absorptive surfaces, optic sources and other optical components can be fabricated and integrated onto a 15 microdevice instrument, providing optical detection capabilities. The status of a reaction may be monitored by illuminating the reagents through an optical window and measuring absorption and/or luminescence. A waveguide may be fabricated by 20 depositing a plane of transparent material between semiconducting planes, or by bonding two wafers together, at least one of the wafers having a transparent surface layer. The optical path of the waveguide is parallel to the fabrication surface. 25 Alternatively, a window which an optical path parallel to the normal vector of the fabrication surface may be constructed using standard patterning techniques. Data analyses can be accomplished with on-board electronics which may provide electronic or 30 optical output.

Analysis of PCR products, sequences of target DNA, or synthetic analogues in microdevices can be accomplished with the manipulative capabilities of microfabricated electrical and mechanical machines. For example, two-dimensional

arrays of pre-determined DNA sequences (probes) can be used to detect or verify PCR products, and their subsequent analyses can be accomplished with microdevices.

As shown in FIG. 1, an embodiment 20 of the present invention is shown above a recess 105 in a power source/control system 100. A hypodermic need 110 is shown inserting a sample through a silicone rubber window 120 into a reaction instrument 20.

The reaction is controlled and powered by: inductive coupling, such as that between coil L_{CL} in the instrument 20 and a magnetic coil 130 as shown in FIG. 2; by capacitive coupling, such as that between the plates of capacitor C₃ and plates 140a and 140b; and by electromagnetic coupling between resonant circuit (not shown) in the instrument 20 and a radiofrequency antenna 135.

A schematic of a preferred embodiment 20 of the present invention is shown in FIG. 2. 20 reagent chambers 10, 12 and 14 contain reactants. One chamber 10 contains the DNA primers, one chamber 12 contains the polymerase, and one chamber 14 contains the nucleotides and any detection-tag molecules, such as magnetic beads. The contents of 25 the chambers 10, 12 and 14 have been loaded at the factory. The target DNA molecule is placed in reagent chamber 10 by insertion of a hypodermic needle or the like through silicone rubber window 120. The window 120 may alternatively be composed of 30 any other type of appropriate natural or synthetic elastomer. The reactants in the reagent chambers 10, 12 and 14 are connected by channels 22, 24 and 26 to a reaction chamber 30. Typically the chambers 10, 12, 14 and 30 have a volume ranging from microliters 35 to nanoliters. The channels 22, 24 and 26 are

equipped with Lamb-wave pumps LW₁, LW₂ and LW₃, respectively, for pumping the reactants in the reactant chambers 10, 12 and 14 in the directions of the arrows to the reaction chamber 30. The Lamb-wave pumps may be located on any wall, or on multiple walls, of the channels 22, 24 and 26. Lamb-wave pump LW₁ is connected to a capacitor C₁. Similarly the other two Lamb-wave pumps LW₂ and LW₃ are connected to capacitors C₂ and C₃, respectively.

The surface tension across the narrow midsections of the channels 22, 24 and 26 prevents the reactants from flowing into the reaction chamber 30 until pumping is initiated. The surfaces of the channels 22, 24 and 26 may be treated to raise the surface tension thereby further inhibiting flow of reagents when the pumps LW₁, LW₂ and LW₃ are not activated.

The reaction chamber 30 may be equipped with a Lamb-wave transducer LW_C and a heater H_C . The Lamb-wave transducer is connected to inductor L_{CL} . The heater H_C is connected to a resonant circuit consisting of an inductor L_{CH} and a capacitor C_{CH} . The Lamb-wave transducer LW_C acts as an agitator, mixer, or sonochemical inducer.

A channel 32 connects the reaction chamber 30 to a detection chamber 34. The channel 34 is equipped with a Lamb-wave pump LWDP, which is connected to a resonant circuit consisting of an inductor LDP and a capacitor CDP. The detection chamber 34 is equipped with a Lamb-wave sensor LWD. The Lamb-wave sensor LWD is connected to a capacitor CD.

For ease of notation, an exemplary Lambwave device chosen from the set LW1, LW2, LW3, LWC, LW_{DP}, and LW_D will be denoted by LW and the corresponding capacitor and/or inductor electrically 5 connected to the Lamb-wave device will be denoted by C and L, respectively, hereinafter. Lamb-wave transducers have high mechanical Q values and can therefore be powered by only a narrow range of alternating voltage frequencies. The Lamb-wave pumps 10 LW_1 , LW_2 , and LW_3 , and the Lamb-wave sensor LW_D are powered capacitively by generating an electric field between the plates 140a and 140b at the resonant frequencies of the Lamb-wave transducers LW1, LW2, LW3, and LWp. The alternating frequency electric 15 fields generate alternating frequency voltages across the capacitors C_1 , C_2 , C_3 and C_D , and Lamb waves at this frequency in the transducers LW1, LW2, LW3 and But because the transducers LW1, LW2, LW3, and LW_D have high Q values, only when the frequency of 20 the imposed field is near the resonant frequency of a transducer does the transducer vibrate with any substantial magnitude. Similarly, the Lamb-wave mixing chamber transducer LWc is powered by an alternating frequency magnetic field generated by the 25 coil 130 at the mechanical resonant frequency of the transducer LWc. The heater Hc and the Lamb-wave pump LW_{DP} are activated by directing an electromagnetic wave from the antenna 135 to the resonant circuits C_{CH} and L_{CH} , and C_{DP} and L_{DP} , respectively. 30 frequency of the incident electromagnetic radiation must correspond to the resonant frequency of the electrical elements Cpp, Lpp and LWpp, and must also correspond to the mechanical resonant frequency of the transducer LW_{DP}, to activate the pump LW_{DP}. 35 frequency of the incident electromagnetic radiation must correspond to the resonant frequency of the

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electrical elements $C_{\rm H},\ L_{\rm CH}$ and $\rm H_{C}$ to activate the heater $\rm H_{C}.$

The PCR reaction is initiated by pumping the reagents in the reagent chambers 10, 12 and 14 5 along the directions of the arrows to the reaction chamber 30 by activating the reagent pumps LW_1 , LW_2 and LW3. A series of approximately twenty to forty thermal cycles are then initiated, during each cycle the temperature of the reactants in the reaction chamber 30 goes from 55°C to 96°C, and back to 55°C, 10 for example. The temperature of the reaction chamber 30 is determined by the power of the incident electromagnetic signal at the frequency corresponding to the resonant frequency of the circuit comprised of 15 the capacitor C_{CH} , and the inductor L_{CH} , together with the heater H_{C} . The reaction chamber 30 Lambwave device LWc acts as an agitator or mixer as described below to mix the reagents and promote the reaction.

When the thermal cycling is complete the contents of the reaction chamber 30 are pumped by Lamb-wave pump LWDP in the direction of the arrow to the detection chamber 34. The preferred embodiment utilizes a Lamb-wave sensor LWD. Alternatively, the detection chamber may be provided with an optical window and testing may be performed by fluorescence-based or absorption-based optical spectroscopy.

A cross-sectional view taken along line 3-3 of FIG. 2 of the reaction chamber 30 is shown in FIG. 30 3. FIGS. 4(a)-(f) show cross-sectional views of the bottom half of the chamber during successive stages of formation of the chamber 30 from a silicon substrate 50b. A similar set of stages are involved in the fabrication of the top portion of the chamber

30. Once fabricated, the top and bottom portions may be bonded together by Mallory bonding.

The chamber cavity 31 is bounded by a ceiling 70t, a floor 70b, and side walls consisting of silicon sections 50t and 50b and silicon nitride sections 49tl, 49bl, 49tr and 49br. The height of the chamber cavity 31 is approximately 0.5 mm, and the width and length of the chamber are approximately 4 mm or less. The whole instrument 20 may fit on a wafer as small as 1 cm x 1 cm x 0.5 cm.

The indentations in the silicon substrates 50b and 50t are formed by coating one side of the substrates 50b and 50t with silicon nitride layers 52b and 52t, and patterning silicon nitride layers on 15 the other sides of the substrates 50b and 50t to form sections 49bl, 49br, 49tl, and 49tr, respectively, as shown in FIGS. 3 and 4(a). The silicon-nitride layers 52t and 52b are preferably applied by lowpressure chemical-vapor deposition of the silicon-20 nitride, and are preferably a low-stress nitride. The thickness of silicon-nitride layers 52t and 52b is chosen to provide a balance between the mechanical strength of the layers which increases with thickness, and the sensitivity of the Lamb-wave 25 detector which decreases with thickness. thickness is also chosen to provide practical resonant frequencies for the device. The thickness of the silicon-nitride layers 52t and 52b is preferably about 3 μ m, plus or minus ten percent.

The system is etched, for example with the wet chemical etchant KOH, to create a cavity in the silicon substrate 50 as shown in FIG. 4(b). The remaining sections of silicon 50bl and 50br form portions of the side walls of the cavity 31.

Located outside the reaction chamber cavity
31 to the exterior of nitride layers 52b and 52t are
top and bottom polycrystalline silicon layers 54t and
54b, respectively. The polycrystalline layers 54t
5 and 54b are deposited on the nitride layers 52b and
52t by chemical vapor deposition and selectively
patterned. The bottom portion of the chamber 30 with
the patterned polycrystalline layer 54b on the
silicon nitride layer 52b is shown in FIG. 4(c). The
10 thickness of the polycrystalline layers 54t and 54b
is preferably between 2000 and 4000 angstroms, and
more preferably 3000 angstroms, plus or minus five
percent.

Top and bottom barrier layers, composed of an insulating material such as low-stress silicon 15 nitride or silicon dioxide, are deposited by lowtemperature oxidation and patterned. The lower barrier layers 58bl, 58bcl, 58bc, 58bcr and 58br lie to the exterior of the polycrystalline layer 54b and 20 the nitride layer 52b as shown in FIG. 4(d). Similarly, the upper barrier layers 58tl, 58tcl, 58tc, 58tcr, and 58tr lie to the exterior of the polycrystalline layer 54t and the nitride layer 52t. Left and right top access holes 64tl, 64tr, 65tl, and 25 65tr provide access to the polycrystalline layer 54t. Similarly, left and right bottom access holes 64bl, 64br, 65bl, and 65br provide access to the bottom polycrystalline layer 54b. The thickness of the barrier layers 58tl, 58tcl, 58tc, 58tcr, and 58tr, 30 (to be collectively referred to as 58t) and 58bl, 58bcl, 58bc, 58bcr and 58br (to be collectively referred to as 58b) is preferably between 1000 and 5000 angstroms, and more preferably 2500 angstroms, plus or minus ten percent. The nitride layers 52b 35 and 52t and the barrier layers 58b and 58t thermally

isolate the polycrystalline layers 54b and 54t from the high conductivity silicon layers 50bl, 50br, 50tl and 50tr, thereby increasing the effectiveness of the heaters formed by the polycrystalline layers 54b and 54t.

As shown in FIGS. 3 and 4(e), top left and right conducting leads 56tl and 56tr, bottom left and right conducting leads 56bl and 56br, top left and right transducers 60tl and 60tr, bottom left and 10 right transducers 60bl and 60br, top left and right four-contact resistance monitoring leads 67tl and 67tr, and bottom left and right four-contact resistance monitoring leads 67bl and 67br are then patterned onto the device. Through access holes 64tl 15 and 64tr, the leads 56tl and 56tr make electrical contact with the polycrystalline layer 54t, and similarly for the bottom section of the chamber 30. Through access holes 65tl and 65tr, the leads 67tl and 67tr make electrical contact with the 20 polycrystalline layer 54t, and similarly for the bottom section of the chamber 30. The top polycrystalline layer 54t is therefore electrically connected to leads 56tl, 56tr, 67tl and 67tr. Similarly, the bottom polycrystalline layer 54b is 25 electrically connected to lead 56bl, 56br, 67bl and 67br. Current passing through polycrystalline layers 54t and 54b generates heat. Therefore, the temperature of the chamber 30 can be controlled by the amount of voltage applied across the top and 30 bottom leads 56tl and 56tr, and 56bl and 56br, respectively. Because the exterior temperature is generally below that of the chemical reactions the system is cooled by the ambient air and cooling elements are not generally required.

The temperature of the system is monitored by measurement of the resistance of the polycrystalline layers 54t and 54b by connecting leads 67tl and 67tr, and 67bl and 67br of four-contact resistance measuring circuits (not shown) to the top and bottom polycrystalline layers 54t and 54b, respectively. The resistance increases linearly with temperature.

- FIG. 5 depicts a view of the bottom of the chamber 30 subsequent to the deposition of the transducers 60bl and 60br, leads 56bl and 56br, and four-contact resistance leads 67bl and 67br, as shown in FIG. 4(e). For clarity not all transducer leads 64blx, 64bly, 64brx and 64bry shown in FIG. 5 are
- depicted in FIGS. 3, 4(e) and 4(f). Only six fingers per transducer 60tl and 60tr are shown in FIGS. 5 for clarity, though transducers having approximately twenty or more fingers are preferred. The cavity 31 and channels 24 and 32 lay beneath the barrier layer
- 20 58b in the region between the dashed lines 29 and the crossbars of the T-shaped leads 56bl and 56br. The access holes 64bl and 64br (not shown in FIG. 5) lie beneath the cross-bars of the leads 56bl and 56br, and the access holes 65bl and 65br (not shown in FIG.
- 5) lie beneath the cross-bars of the leads 67bl and 67br, respectively. The bottom left Lamb-wave transducer 60bl consists of a plurality of interlaced fingers which are electrically connected to a pair of transducer leads 64blx and 64bly. The top left and
- right transducers 60tl and 60tr and the bottom left and right transducers 60bl and 60br have similar shapes. The bottom transducers 60bl and 60br and the bottom transducer leads 64bly, 64blx, 64bry and 64brx, and the leads 56bl, 56br, 67bl and 67br are
- 35 aluminum and have a thickness of preferably 2000 to 6000 angstroms, and more preferably a thickness of

4000 angstroms, plus or minus ten percent. The bottom transducers 60bl and 60br and leads 56bl, 56br, 67bl, and 67br may be alternatively be made of low-temperature oxide, or any other appropriate 5 conducting material. The top transducers 60tl and 60tr and leads 56tl, 56tr, 67tl, and 67tr may be similarly constructed.

As shown in FIGS. 3 and 4(f), a bottom piezoelectric layer 62b extending between and 10 covering leads 67bl and 67br, fingers of the bottom transducers 60bl and 60br, and portions of leads 56bl and 56br is then deposited and patterned. a top piezoelectric layer 62t extending between and covering leads 67tl and 67tr, fingers of the bottom 15 transducers 60tl and 60tr, and portions of leads 56tl and 56tr is then deposited and patterned. piezoelectric material may be ZnO or any other appropriate material. The thickness of the piezoelectric sections 62t and 62b is preferably 20 between 0.5 and 2.0 μ m, more preferably 1 μ m, plus or minus ten percent.

The piezoelectric sections 62t and 62b are covered by top and bottom conducting ground planes 66t and 66b, respectively, as shown in FIGS. 3 and 25 4(f). The ground planes 66t and 66b may be aluminum, or any other appropriate conducting material. thickness of the conducting ground plane layers 66t and 66b is preferably between 2000 and 6000 angstroms, and more preferably 4000 angstroms, plus 30 or minus ten percent.

Lamb waves, also known as plate-mode waves, have a compressional component and a shear component. Together the components of a traveling Lamb-wave in a slab can transport liquids and gases adjacent the

slab, much the same way ocean waves transport a surfing board. Lamb-wave devices can therefore act as pumps. Material near the surface of the slab has the maximum velocity since there are essentially no 5 boundary layer effects. This is extremely advantageous for the small geometries associated with microdevices. FIG. 6a shows the typical flow velocity of a fluid through a conduit with two planar walls to illustrate the effect of the friction 10 induced by walls on the flow. The velocity profile is parabolic, and at the left and right edges of the conduit the velocity drops to zero due to friction between the fluid and the walls. The friction between the walls and the fluid reduces the 15 efficiency of the pumping. In contrast, FIG. 6b shows the flow velocity of a fluid through the same conduit when the front and back walls are Lamb-wave pumps. The flow velocity is almost constant between the right and left walls. The viscosity of the fluid 20 transmits the momentum of the fluid near the Lambwave pumps to the fluid farther from the pumps.

Lamb waves require a propagation medium which is at most several wavelengths thick. The Lamb waves in this invention have frequencies in the approximate range of 1 to 200 MHz, and typical pumping velocities for a Lamb-wave device operated with a 10 volt transducer voltage are 300 μ m/sec for water, and 2 cm/sec for air.

The layers 54t, 58t, 62t and 66t which

30 border the top of the chamber cavity 31 will
hereinafter be referred to as the ceiling 70t of the
chamber 30, and the layers 54b, 58b, 62b and 66b
which border the bottom of the chamber cavity 31 will
hereinafter be referred to as the floor 70b of the

35 chamber 30. Lamb waves are generated in the ceiling

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70t of the chamber 30 by applying an alternating voltage between a transducer lead, for instance the upper left lead 64tly of F 3. 5, and the top ground plane 66t. The transducer electrodes 60tly 5 differentially deform the piezoelectric material 62t to produce a mechanical wave motion in the ceiling The amplitude of the Lamb waves is increased by applying a second alternating voltage which is 180° out of phase to the transducer lead 64tlx connected 10 to the set of interlaced fingers.

Traveling waves are generated in the Lambwave pumps LW₁, LW₂, LW₃, and LW_{DP} in the directions of the arrows of FIG. 2 by application of alternating voltages to the pumps LW1, LW2, LW3, and LWDp at the 15 arrow-tail side. Standing waves are generated in the Lamb-wave detector LWn by application of in-phase alternating voltages electrodes at both sides of the chamber. By sending Lamb-waves from left to right across the ceiling 70t of the mixing chamber 30 (by 20 application of an alternating voltage between top left transducer 60tl and the top ground plate 66t) and Lamb waves from right to left across the floor 70b of the chamber 30 (by application of an alternating voltage between bottom right transducer 60br and the bottom ground plate 66b), a stirring or circulating action can be produced.

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The phenomenon responsible for the operation of the Lamb-wave sensor LW_D in the detection chamber 34 is elastic wave propagation 30 along a medium whose characteristics can be altered by a measurand, such as viscosity or density of the ambient fluid or gas. Where the characteristics of the waves propagating along the medium are dependent upon the characteristics of the propagation medium, the wave characteristics can be monitored or measured

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to provide an indication of the measurand value. For example, when the device absorbs vapors or gases from the atmosphere in a film deposited on the surface, the output frequency changes. Tests and analysis indicate that Lamb-wave sensors are at least an order of magnitude more sensitive than other types of acoustical vapor sensors operating at the same wavelength. The type of DNA in an ambient fluid can be determined by measuring the viscosity as a function of temperature, since the denaturing temperatures of different types of DNA are well known.

Since Lamb-wave sensors can operate while in contact with a liquid such as water, their use as biosensors is very significant. For instance, the 15 surface of a Lamb-wave sensor may be coated with single strands of a particular DNA molecule. If the device is immersed in a solution containing that same type of DNA molecule, the molecules in solution will 20 pair with the molecules on the surface, increasing the mass of the membrane and therefore decreasing the frequency of oscillation. Also, the membrane may be made of a porous and permeable material, allowing the coating of a greater surface area and also allowing the liquid to be flowed through the membrane, in order to speed up the DNA attachment. Intercalating dyes, such as ethidium bromide, may be used to augment viscosity changes which occur during a reaction, thereby increasing the sensitivity of the 30 sensor. Other biological interactions may also be sensed.

Figure 7 shows gel electrophoresis results verifying the amplification of a specific HIV nucleic acid sequence performed by the microfabricated reaction instrument of the present invention. The

two outside bands C_1 and C_2 represent calibrating size standards, and the three bands labelled as D_1 represent the DNA amplified in the microreactor. The two bands E_1 to the left of center are results obtained with a commercial PCR thermocycler instrument from the same reaction mixture as that in the microreactor. Since bands E_1 and D_1 are at the same height it is indicated that the microreactor has produced the correct target. The thermal cycles of the commercial instrument were 4 minutes long. Those of the microreactor of the present invention were 1 minute in length.

In summary, an apparatus and method for in situ chemical reactions in a microfabricated

15 instrument has been described. It has been shown that the instrument facilitates extremely rapid thermal cycling and high-precision temperature control of microliter to nanoliter volumes. The apparatus and method are well suited for DNA-based

20 reactions, such as PCR. It has also been shown that such integrated devices minimize the possibility for contamination of the reactions and may be operated at a distance by electromagnetic fields.

The present invention has been described in terms of a preferred embodiment. However, the invention is not limited to the embodiment depicted and described. Many variations within the scope of the present invention are possible. For instance, the instrument may consist of a series of chambers at different temperatures, and the temperature programming of the reagents may be accomplished by transport of the reagents through the series of chambers. The instrument may have an input channel and an output channel, and may be adapted to provide a continual flow-through synthesis. Thermal cycling

may be accomplished by repeated transfer of reagents between two or more chambers which are heated to different temperatures.

In another alternate embodiment the monitoring of the temperature of a chamber is accomplished at a distance by connecting an LC circuit to a probe across a polycrystalline heating layer and measuring the Q-factor of the circuit. Q-factor is measured by exciting the circuit with an incident electromagnetic field at the resonant frequency of the circuit and monitoring the time decay of the resonance, or by measuring the bandwidth of the circuit by applying a frequency modulated incident EM field and measuring the circuit's frequency response. Since the measured Q-factor is 15 inversely proportional to the resistance and the resistance increases linearly with temperature, the temperature may be determined by the measured Qfactor.

20 Other possible variations within the spirit of the invention include: the dimensions of components of the instrument are not limited to those disclosed; more or fewer reactants may be used and the reactants may be organic, inorganic, or a combination of organic and inorganic; the detection 25 means may be located in the same chamber as the mixing means; components of the device may be made of semiconducting materials other than silicon, or of quartz, glass, polymers or other materials; the microfabricated instrument may be formed by the bonding of two wafers; the instrument may be provided with optical windows for optical monitoring of the reaction; the instrument may be controlled by direct electrical coupling of control circuitry to the leads of the pumps, heater and sensor; a 35

silicone-rubber window may form a penetrable wall of any chamber or channel; the instrument may be fabricated from a silicon-rased material; the instrument may be powered by an integrated

microfabricated battery; any Lamb-wave transducer may be activated by capacitive, inductive, electromagnetic or optical means; or electrokinetic pumps, or any other appropriate type of pumping means, may be substituted for the Lamb-wave pumps.

Accordingly, the scope of the invention is defined by the appended claims.

WHAT IS CLAIMED IS:

- An instrument for controlling a chemical reaction of reagents comprising: integrated microfabricated elements, said elements including a first reagent chamber for containment of a first one of said reagents, and a means for manipulation of a parameter of said reaction.
- The instrument of claim 1 wherein said microfabricated elements include a control means for controlling said means for manipulation, and a power source for powering said control means.
 - 3. The instrument of claim 2 wherein said power source comprises a battery.
- 4. The instrument of claim 1 further including a control means for controlling said means for manipulation, said control means being coupled to said means for manipulation by optical radiation.
 - 5. The instrument of claim 1 further including a control means for controlling said means for manipulation, said control means being coupled to said means for manipulation by electromagnetic radiation.
 - 6. The instrument of claim 1 further including a control means for controlling said means for manipulation, said control means being coupled to said means for manipulation by an electromagnetic field.
- The instrument of claim 6 wherein said electromagnetic field is substantially comprised of an electric field.

- 8. The instrument of claim 6 wherein said electromagnetic field is substantially comprised of a magnetic field.
- 9. The instrument of claim 1 wherein said instrument has an exterior surface, further including an optical window between said first reagent chamber and said exterior surface, whereby exterior light may be directed to contents of said first reagent chamber through said window.
- 10 10. The instrument of claim 1 wherein one of said elements comprises a Lamb-wave transducer at a boundary of said first chamber.
 - 11. The instrument of claim 1 wherein said means for manipulation comprises an ultrasound transducer.
- 15 12. The instrument of claim 1 wherein said means for manipulation comprises an electromagnetic radiation transducer.
- 13. The instrument of claim 1 wherein said means for manipulation comprises a means for heating said first20 chamber.
 - 14. The instrument of claim 13 wherein said means for heating comprises a resistive element near said first chamber.
- 15. The instrument of claim 14 wherein said 25 resistive element is substantially thermally isolated.
 - 16. The instrument of claim 14 wherein said resistive element is substantially thermally isolated by an envelope of a low-stress material.

- 17. The instrument of claim 16 wherein a portion of said envelope forms a portion of a wall of said chamber.
- 18. The instrument of claim 17 wherein said low-5 stress material is low-stress silicon nitride.
 - 19. The instrument of claim 1 further including a boundary layer forming a wall of said chamber, said boundary layer being comprised of a low-stress material.
- 10 20. The instrument of claim 19 wherein said lowstress material is low-stress silicon nitride.
 - 21. The instrument of claim 14 further comprising a resonant circuit electrically connected to said resistive element, a means for exciting said resonant
- circuit at a distance, and a means for monitoring the energy stored in said resonant circuit at a distance, whereby the Q-factor of said resonant circuit may be monitored at a distance, thereby determining the resistance of said resistive element and the
- 20 temperature of said resistive element.
 - 22. The instrument of claim 13 wherein said means for heating produces a predetermined sequence of temperatures in said first chamber.
- 23. The instrument of claim 13 wherein said means
 25 for heating produces a number of thermal cycles in said first chamber.
 - 24. The instrument of claim 23 wherein said number is greater than ten.

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- The instrument of claim 23 wherein said number is greater than twenty five.
- 26. The instrument of claim 23 wherein one of said elements comprises a second reagent chamber, and one 5 of said elements comprises a means for pumping said first reagent between said first chamber and said second chamber.
 - The instrument of claim 26 wherein said means for pumping comprises a Lamb-wave transducer.
- The instrument of claim 26 wherein said means 10 for pumping comprises a differential temperature pump.
- The instrument of claim 1 wherein one of said elements comprises a second reagent chamber, and one 15 of said elements comprises a means for pumping said first reagent between said first chamber and said second chamber.
 - The instrument of claim 29 wherein said means for pumping comprises a Lamb-wave transducer.
- The instrument of claim 1 wherein one of said 20 elements comprises a means for determining the progress of said reaction.
- The instrument of claim 31 wherein said means for determin ng comprises a sensor for monitoring the 25 viscosity of one of said reagents.
 - 33. The instrument of claim 32 wherein one of said reagents comprises an intercalating molecule which augments a viscosity change associated with said reaction.

- 34. The instrument of claim 33 wherein said intercalating molecule intercalates into a deoxyribonucleic acid.
- 35. The instrument of claim 33 wherein said sensor5 comprises a flexural wave sensor.
 - 36. The instrument of claim 32 wherein said sensor comprises a flexural wave sensor.
 - 37. The instrument of claim 33 wherein said reagents include a deoxyribonucleic acid.
- 10 38. The instrument of claim 33 wherein said reagents include a ribonucleic acid.
 - 39. The instrument of claim 33 wherein said reagents include a polymer.
- 40. The instrument of claim 33 wherein said reagents include a large molecule.
 - 41. The instrument of claim 33 wherein said reagents include a protein.
 - 42. The instrument of claim 27 wherein one of said chambers has a capacity of less than a milliliter.
- 20 43. The instrument of claim 27 wherein one of said chambers has a capacity of less than fifty microliters.
 - 44. The instrument of claim 27 wherein one of said chambers has a capacity of less than a microliter.
- 25 45. The instrument of claim 26 wherein one of said chambers has a capacity of less than a picoliter.

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- 46. The instrument of claim 1 wherein one of said elements comprises a means for stirring the contents of said first chamber.
- 47. The instrument of claim 46 wherein one of said elements comprises a Lamb-wave transducer at a boundary of said chamber, thereby preventing boundary layer effects from reducing the effectiveness of the stirring.
- 48. The instrument of claim 1 wherein one of said elements comprises an elastomeric window interposed between a boundary of said first reagent chamber and the exterior of said instrument, whereby a second reagent may be inserted into said first chamber by puncturing said window with a hollow needle.
- 15 49. The instrument of claim 1 further including a hypodermic needle means for extracting a body fluid, said needle means having a fluid conduit terminating at said first chamber.
- 50. The instrument of claim 1 wherein said 20 microfabricated elements are formed on a semiconducting substrate.
 - 51. The instrument of claim 50 wherein said semiconducting substrate is composed of a silicon-based material.
- 25 52. The instrument of claim 1 wherein said microfabricated elements are formed on a substrate composed of a polymer.
- 53. The instrument of claim 1 wherein said microfabricated elements are formed on a substrate composed of a glass.

- 54. The instrument of claim 1 wherein one of said reagents is an organic compound.
- 55. The instrument of claims 1 wherein one of said reagents is an inorganic compound.
- 5 56. The instrument of claim 1 wherein one of said reagents is a biochemical compound.
 - 57. The instrument of claim 1 wherein one of said reagents is a nucleic acid.
- 58. The instrument of claim 1 wherein one of said 10 reagents is a protein.
 - 59. The instrument of claim 1 wherein said chemical reaction is a chain reaction.
 - 60. The instrument of claim 59 wherein said chain reaction is a polymerase chain reaction.
- 15 61. The instrument of claim 59 wherein said chain reaction is a ligase chain reaction.
 - 62. The instrument of claim 1 wherein said chemical reaction is comprised of a plurality of substantially similar subreactions.
- 20 63. The instrument of claim 62 wherein said chemical reaction produces a quantity of a target product:
 - 64. The instrument of claim 63 wherein said quantity of said target product increases exponentially with each said subreaction.

- 65. The instrument of claim 63 wherein said target product increases linearly with each said subreaction.
- 66. The instrument of claim 56 wherein said chemical reaction is a polymerase chain reaction.
 - 67. An instrument for controlling a chemical reaction, said chemical reaction producing a product from a set of reagents, said instrument comprising: integrated microfabricated elements, said elements
- including an array of chambers for containment of reagents of said reaction, a plurality of channels interconnecting said chambers, and a means for transferring said reagents between said chambers by way of said channels.
- 15 68. The instrument of claim 67 wherein said elements further include a first heating means for maintaining a first one of said chambers at a first temperature and a second heating means for maintaining a second one of said chambers at a second temperature.
- 20 69. The instrument of claim 67 wherein said instrument has an exterior surface and further including an optical window between a first selected chamber and said exterior surface.
- 70. The instrument of claim 68 wherein said means for transferring includes means for repeatedly transferring said reagents located in said first chamber to said second chamber and repeatedly transferring said reagents located in said second chamber to said first chamber.

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- 71. The instrument of claim 67 further including a means for manipulation of a parameter of said reaction:
- 72. The instrument of claim 67 wherein said chambers
 5 in said array are interconnected substantially in series by said channels.
 - 73. The instrument of claim 72 further comprising an input channel and an output channel, a subset of said reagents being continually introduced to said instrument through said input channel, and said product being continually extruded from said instrument through said output channel.
- 74. The instrument of claim 73 further including a plurality of heaters, said heaters being located
 15 proximate said chambers and maintaining said chambers at a plurality of temperatures, whereby transport of said reagents through said chambers subjects said reagents to said plurality of temperatures.
- 75. The instrument of claim 67 wherein said means 20 for transferring comprises an active pumping means.
 - 76. The instrument of claim 75 wherein said active pumping means comprises a Lamb-wave pump.
 - 77. The instrument of claim 67 wherein said means for transferring comprises a passive pumping means.
- 78. The instrument of claim 77 wherein said passive pumping means comprises a heating means proximate a chamber selected from said array of chambers for heating contents of said selected chamber, whereby said contents may be forced from said selected

 30 chamber by heating said contents with said heating

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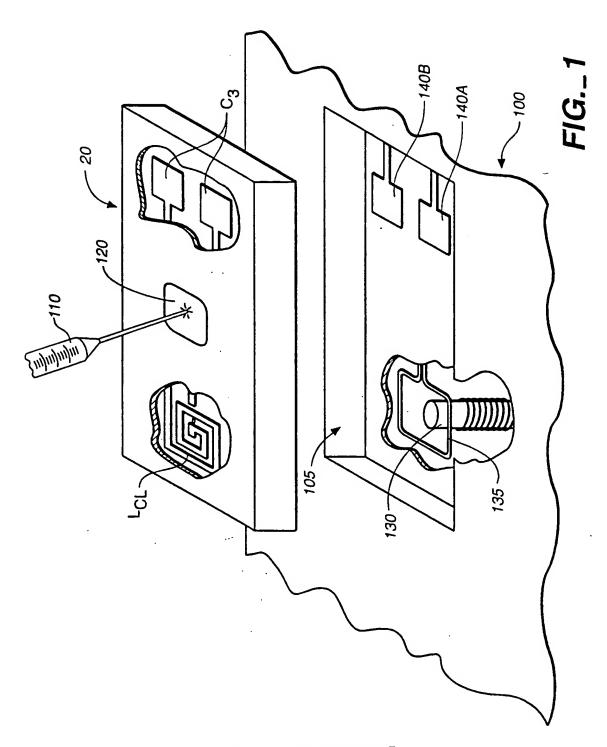
means and thereby increasing the volume of said contents.

- 79. The instrument of claim 67 wherein said array of chambers is comprised of a plurality of substantially5 similar groups of chambers.
- 80. The instrument of claim 79 wherein chambers within a first group are fluidicly interconnected, and chambers within said first group are substantially isolated from chambers within a second group.
- 81. A process for manufacturing on a wafer an instrument for controlling a chemical reaction, comprising the steps of etching said wafer to form a reaction chamber, and depositing a resistive element on said wafer adjacent a boundary of said reaction chamber.
- 82. The process of claim 81 further comprising the steps of etching a reagent chamber and etching a passage from said reagent chamber to said reaction chamber.
 - 83. The process of claim 81 further comprising the step of depositing a Lamb-wave transducer on said wafer.
- 84. The process of claim 83 wherein said Lamb-wave 25 transducer is located near a boundary of said reaction chamber.
- 85. The process of claim 81 further comprising the step of depositing a window of an elastomeric material interposed between a boundary of one of said chambers and the exterior of said wafer.

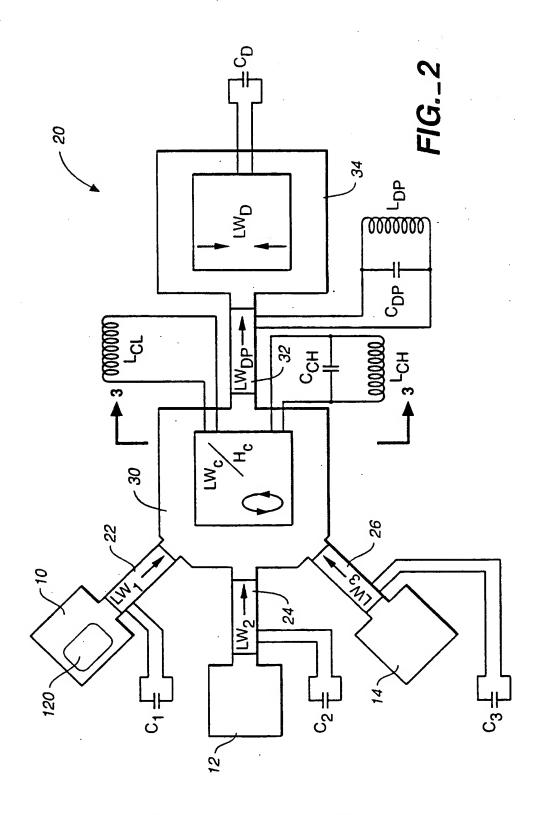
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- 86. The process of claim 81 wherein said wafer comprises a semiconductor.
- 87. The process of claim 86 wherein said semiconductor comprises a silicon-based material.
- 5 88. A microfabricated mixing chamber comprising at least one Lamb-wave transducer for stirring contents of said chamber, thereby preventing boundary layer effects from reducing the effectiveness of the stirring.
- 10 89. A microfabricated chamber comprising at least one Lamb-wave transducer for viscosity measurements of contents of said chamber, thereby preventing boundary layer effects from reducing the effectiveness of the stirring.
- 15 90. An instrument for controlling a chemical reaction of reagents comprising: integrated microfabricated elements, said elements including
 - a reagent chamber for containment of a first one of said reagents, said chamber having a first wall and a second wall.
 - a first Lamb-wave transducer located near said first wall; and
 - a second Lamb-wave transducer located near said second wall.
- 25 91. The instrument of claim 90 wherein said first and second walls are located at opposite sides of said chamber.
- 92. The instrument of claim 91 wherein said first Lamb-wave transducer has two sets of interlaced 30 transduction leads, and said second Lamb-wave

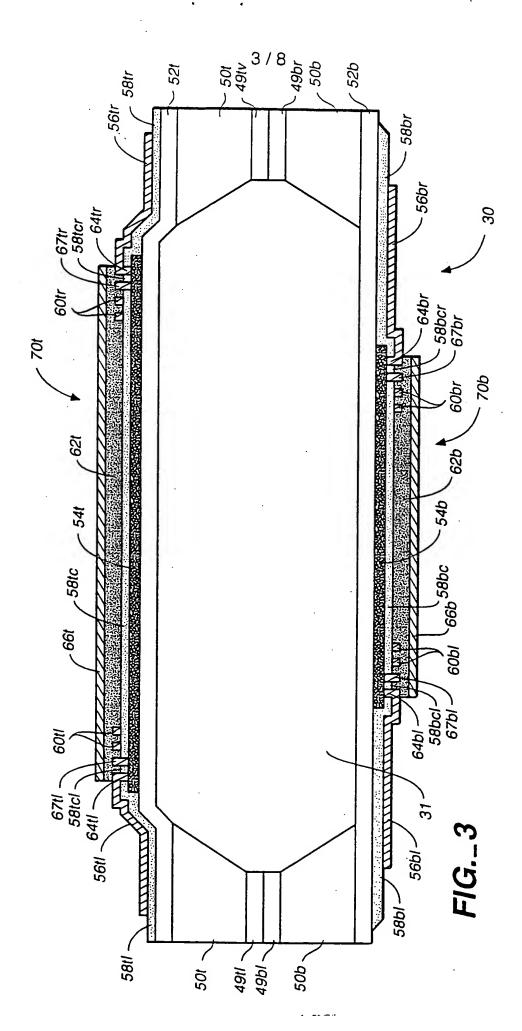
transducer has two sets of interlaced transduction leads.



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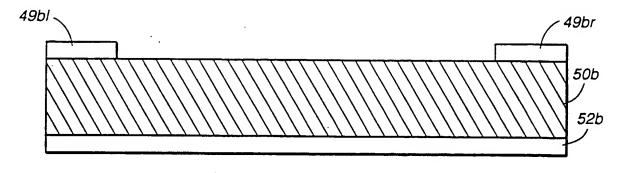


FIG._4A

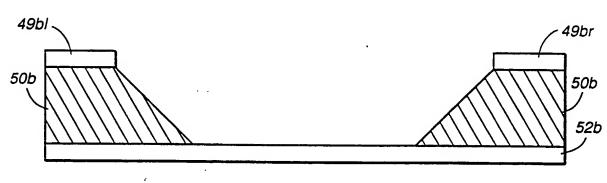


FIG._4B

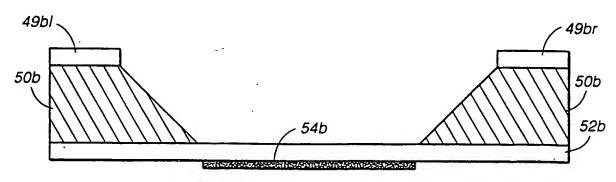
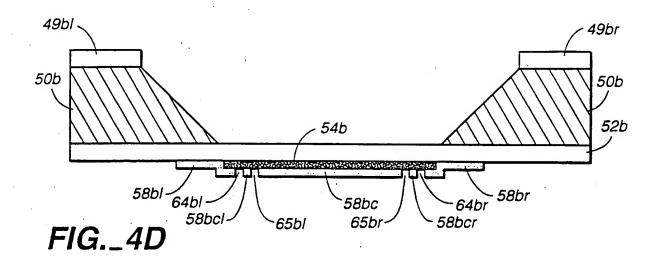
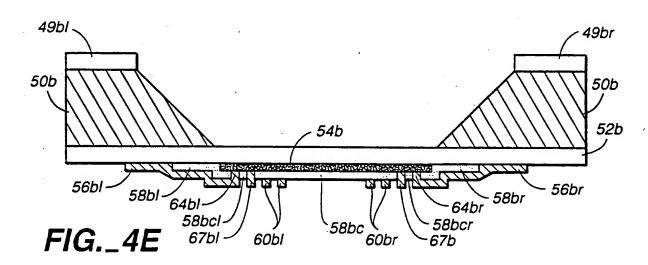
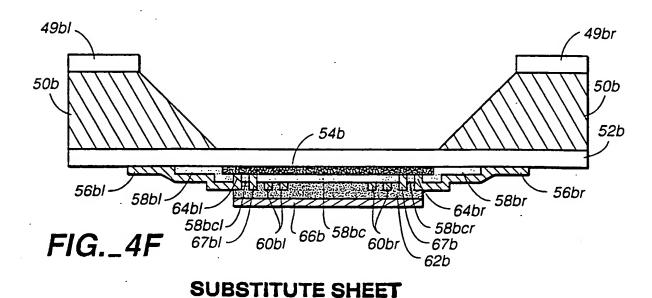


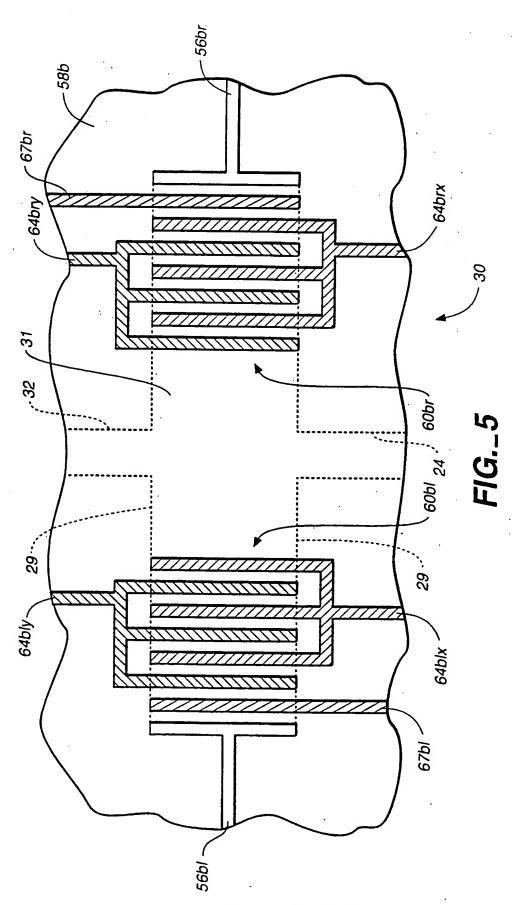
FIG._4C

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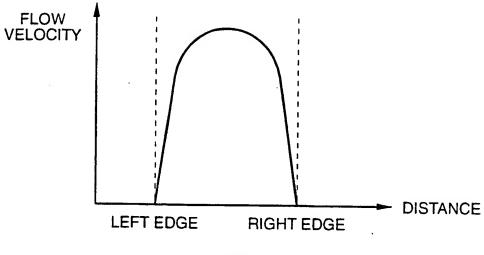


FIG._6A

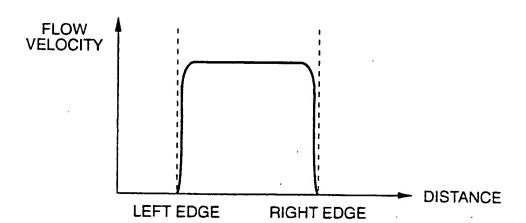


FIG._6B

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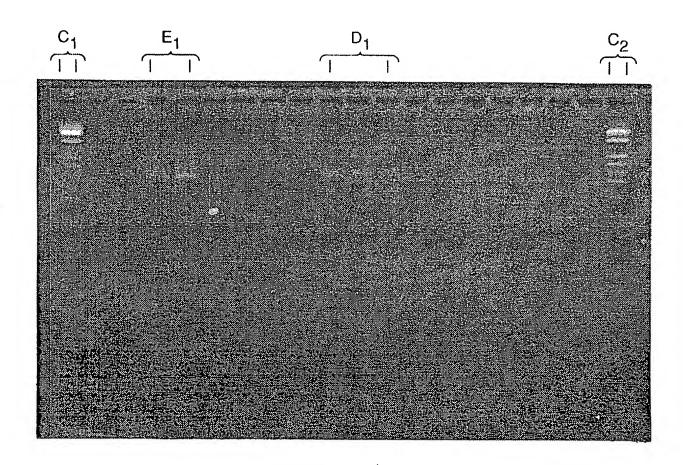


FIG._7

IPC(5) :B01F 11/02; C03C 25/06; C12M 1/00 US CL :156/647, 657, 662; 422/50; 435/287; 366/127					
According to International Patent Classification (IPC) or to both national classification and IPC					
	DS SEARCHED				
Minimum d	Minimum documentation searched (classification system followed by classification symbols)				
U.S. :	68/3SS; 73/52.41; 156/647, 657, 662; 422/50; 435/2	87; 366/127			
Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched					
Electronic data base consulted during the international search (name of data base and, where practicable, search terms used) APS search terms: lamb wave, transducer, sensor, pump					
C. DOCUMENTS CONSIDERED TO BE RELEVANT					
Category*	Citation of document, with indication, where ap	propriate, of the relevant passages	Relevant to claim No.		
Y	US, A, 5,006,749 (White) 09 April 19	91, see entire document.	1-92		
Y	US, A, 5,000,817 (Aine) 19 March 1991, see entire document.		1-92		
Y,P	US, A, 5,220,189 (Higashi et al.) 15 June 1993, see entire document.		1-92		
Y	US,A, 4,960,486 (Perkins et al.) 02 October 1990, col. 3, lines 4-12, 44-68.		85		
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X Further documents are listed in the continuation of Box C. See patent family annex.					
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24 November 1993		16 DEC 1993 Authorized officer ROBERT J. WARDEN			
Name and mailing address of the ISA/US Commissioner of Patents and Trademarks Box PCT		Authorized officer ROBERT J. WARDEN Authorized officer ROBERT J. WARDEN			
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•	tion). DOCUMENTS CONSIDERED TO BE RELEVANT	<u> </u>
Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No
Y	US, A, 5,003,822 (Joshi) 02 April 1991, see entire docuemnt, especially col. 1, lines 64-67, col. 3, lines 30-43, col. 4, lines 10-	1-87,90-92
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r	IEEE Spectrum, issued July 1990, R.T. Howe et al., "Silicon Micromechanics: Sensors and Actuators on a Chip", pages 29-35, see entire document.	81-92
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r	DE, A, 3,811,052 (Kroy et al.) 24 August 1989, figures 1-2, and 4.	81-92
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